

High field, high repetition rate kicker

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KEK

Aimed for :

Injection & Extraction of PRISM/FFAG muon beam

Injection & Extraction of 50 GeV proton beam

Requirements :

- Large aperture
 - 50 GeV : Gap height 100mm
 - PRISM/FFAG : Gap height 200mm ?

- High field
 - 50 GeV : 1 kGauss or more (if possible)
 - PRISM/FFAG : 0.5kGauss ?

- High repetition rate
 - PRISM/FFAG : 1 kHz

- Simple and maintenance-free system
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Near-future R&Ds for PRISM/FFAG Kickers

for Higher Voltage :
for Higher Current :

---> more IGBT modules. (possible)

Shorter Rise-time:
(esp. for PRISM extraction, ~100nsec)

---> use of MOS-FETs.
(faster, but more module should be used)

---> use of magnetic pulse compression circuits?

Extraction Kicker Power Supply

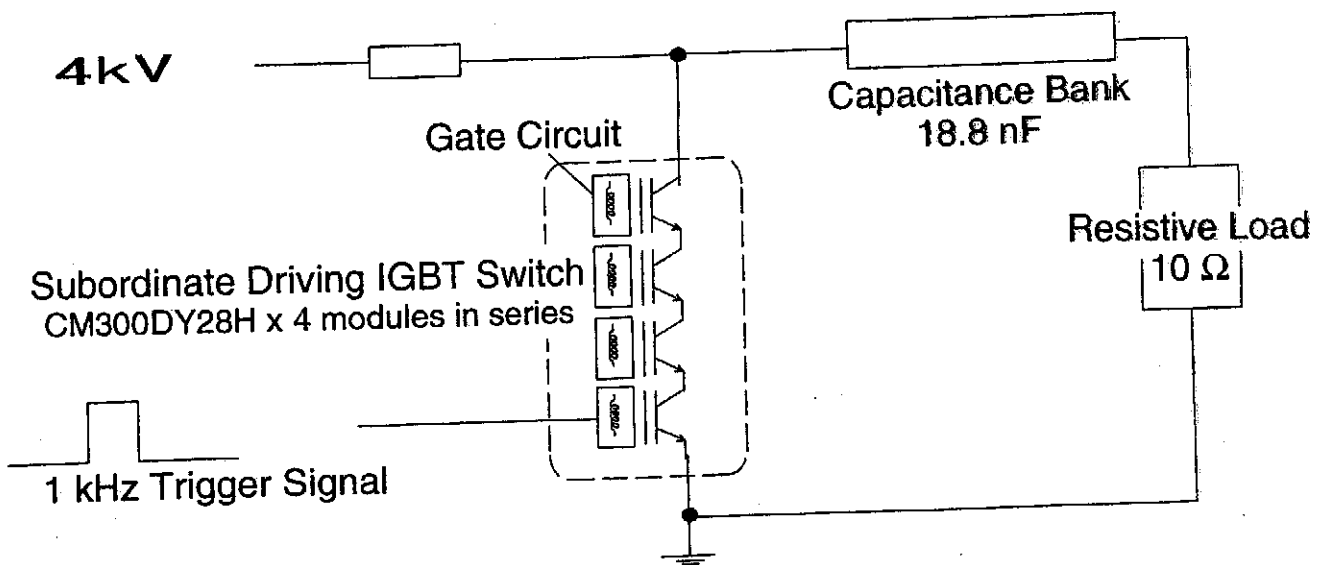
with 1 kHz Operation

---now on construction (for other purpose)

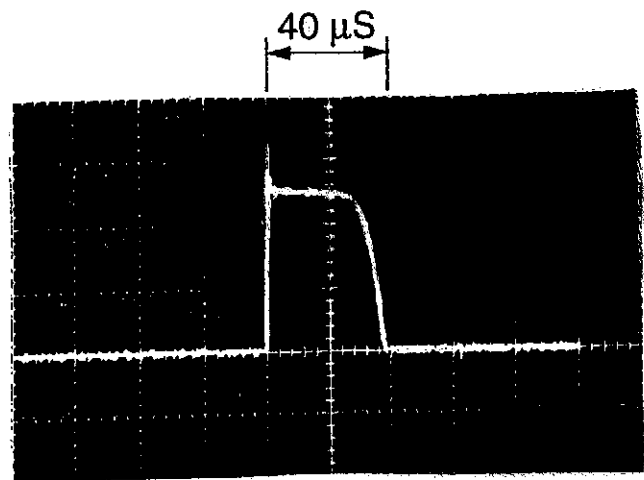
Field strength : ~1 kGauss
Rise-time : 250 ~ 300nsec
Flat-top : 200 nsec
Field flatness : $\pm 2.5\%$
Output voltage : 35 kV (Max.)
Output current : 750 ~ 1000 A
Impedance : 25 Ω
IGBT module :

CM75DY-28H (1400V/300A)

x 36 in series x 4 in parallel

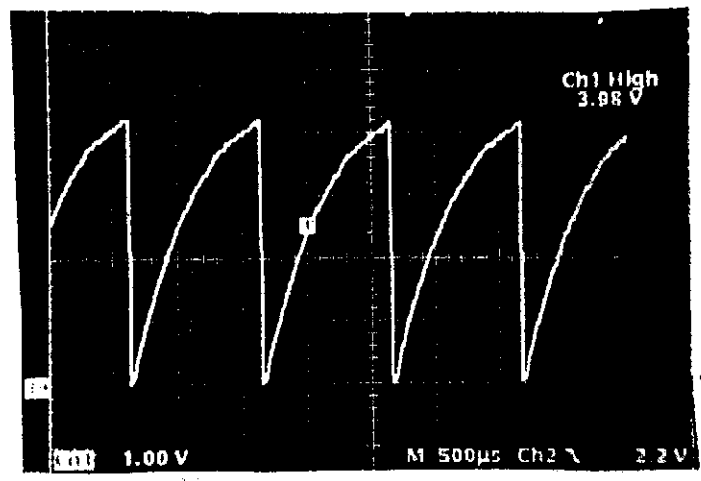


Test Circuit



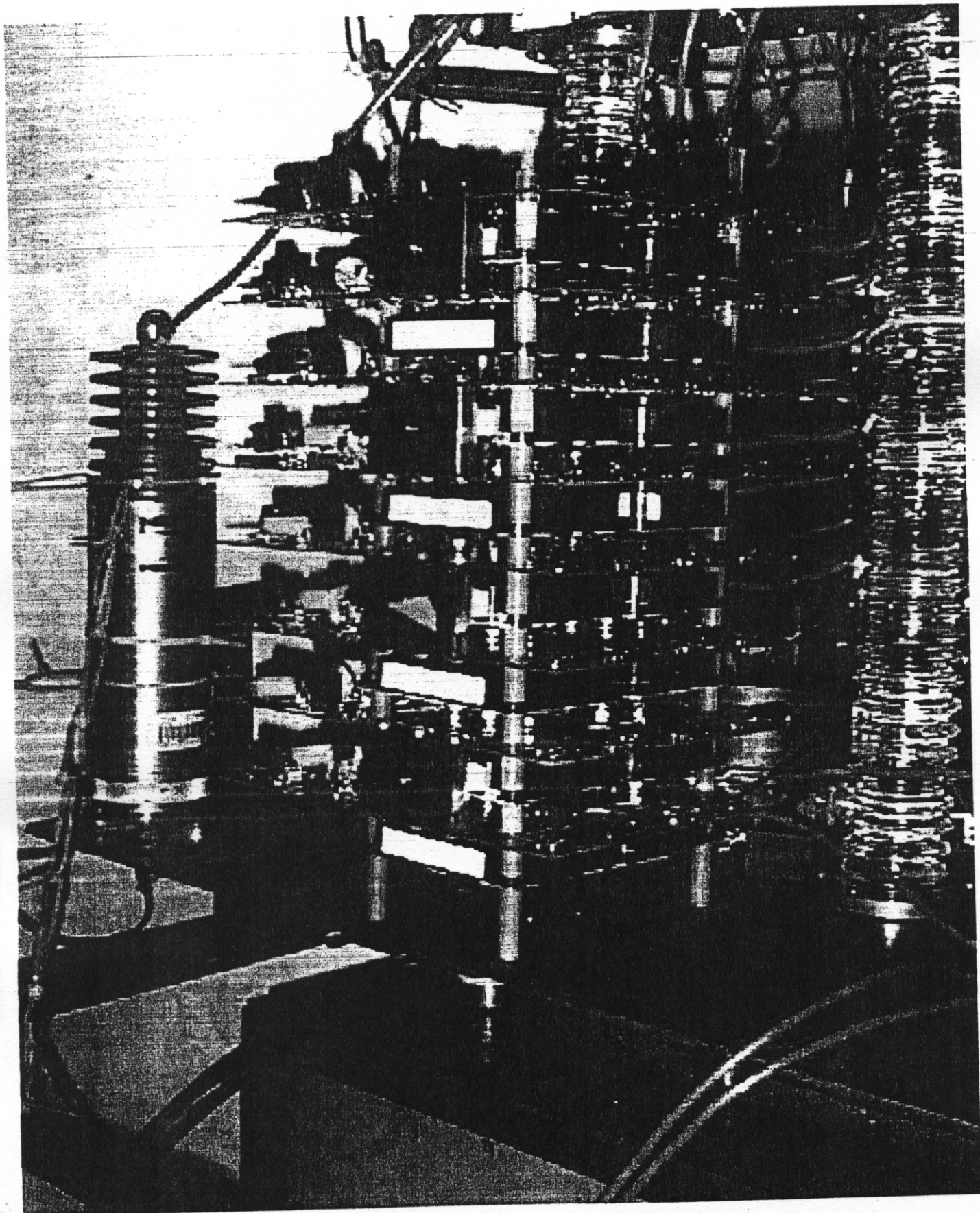
10V/div
20 μ s/div

Trigger Signal Waveform

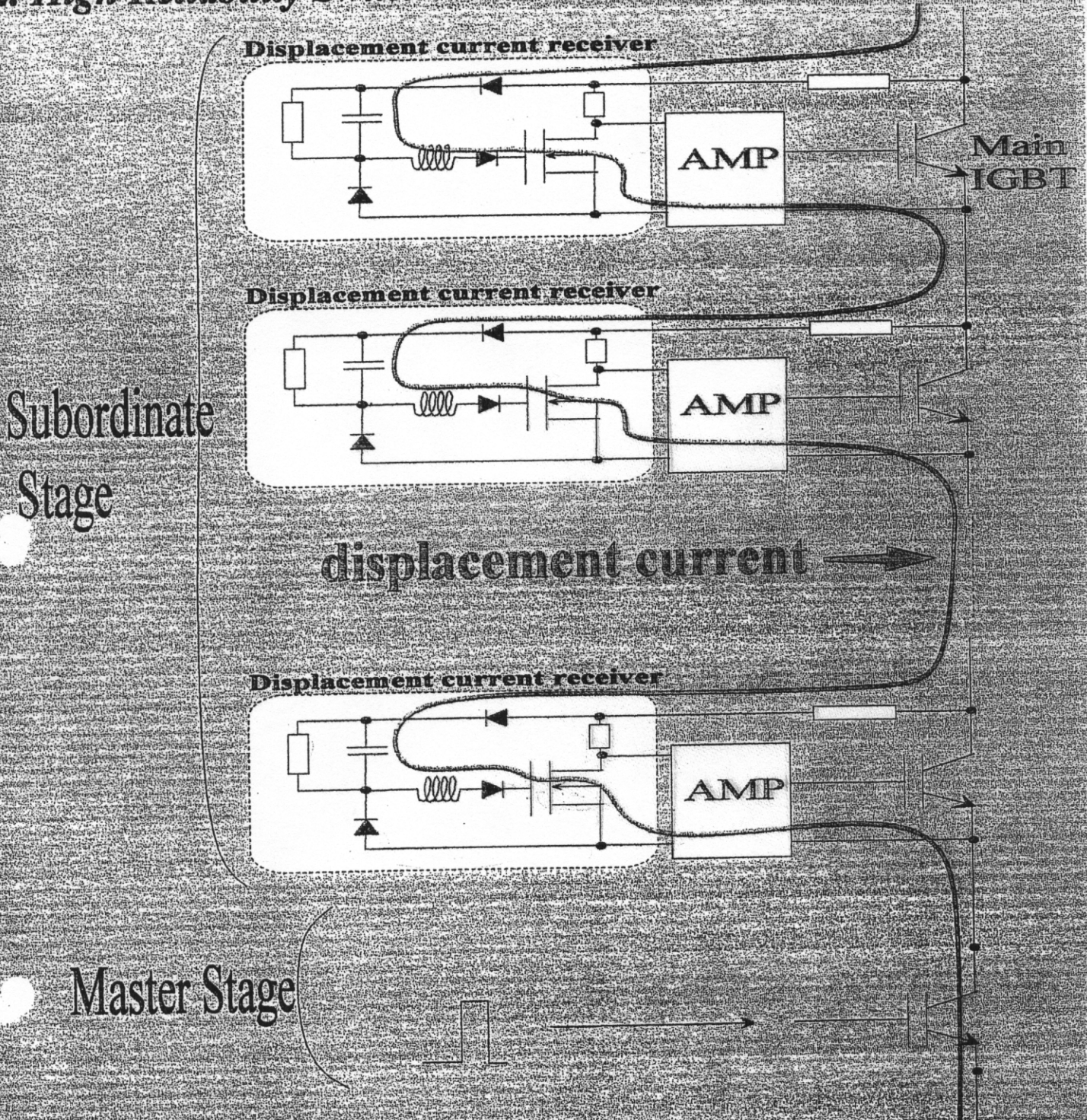


1kV/div
500 μ s/div

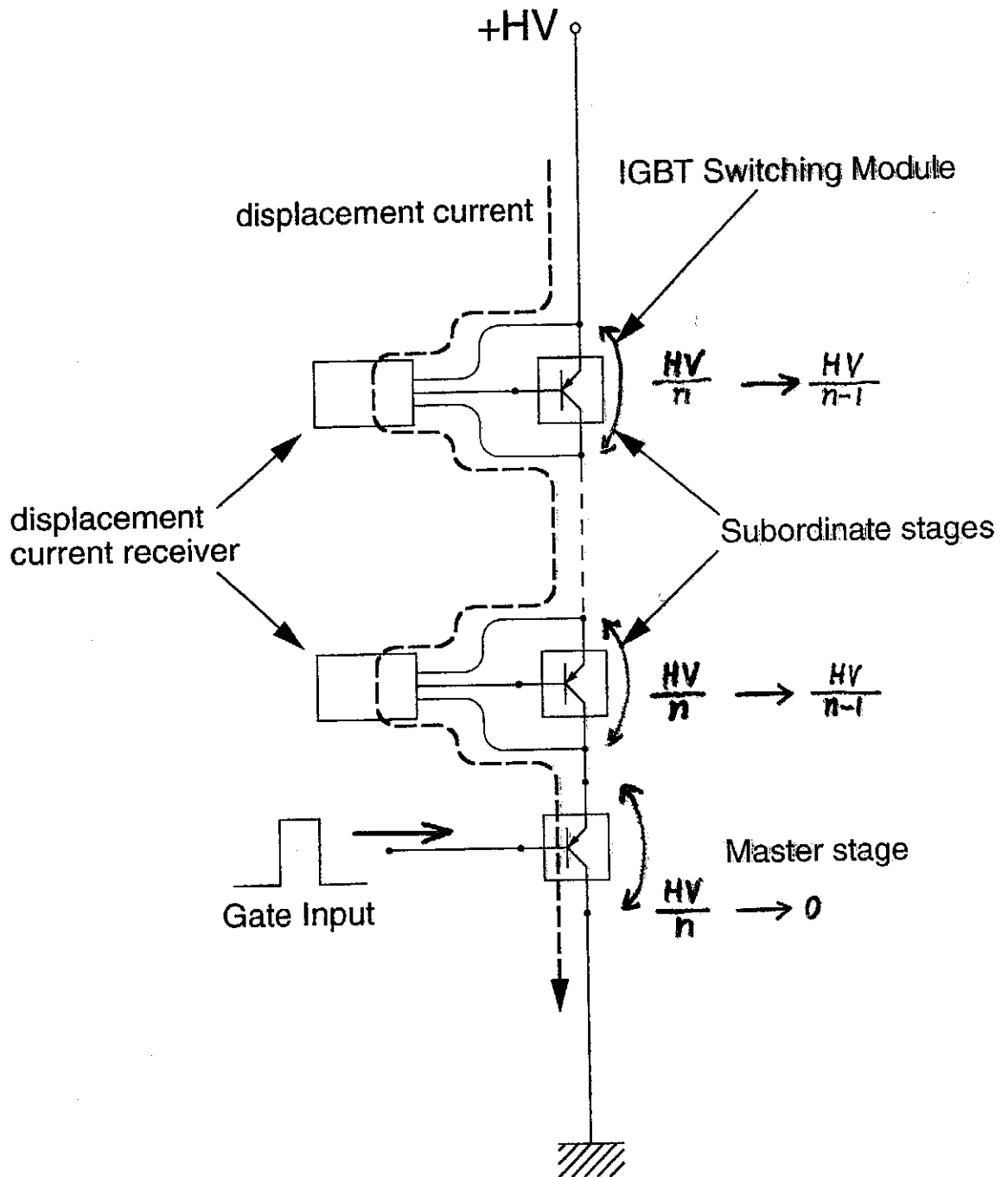
Voltage across 4-Series IGBTs



2. High Reliability Switch

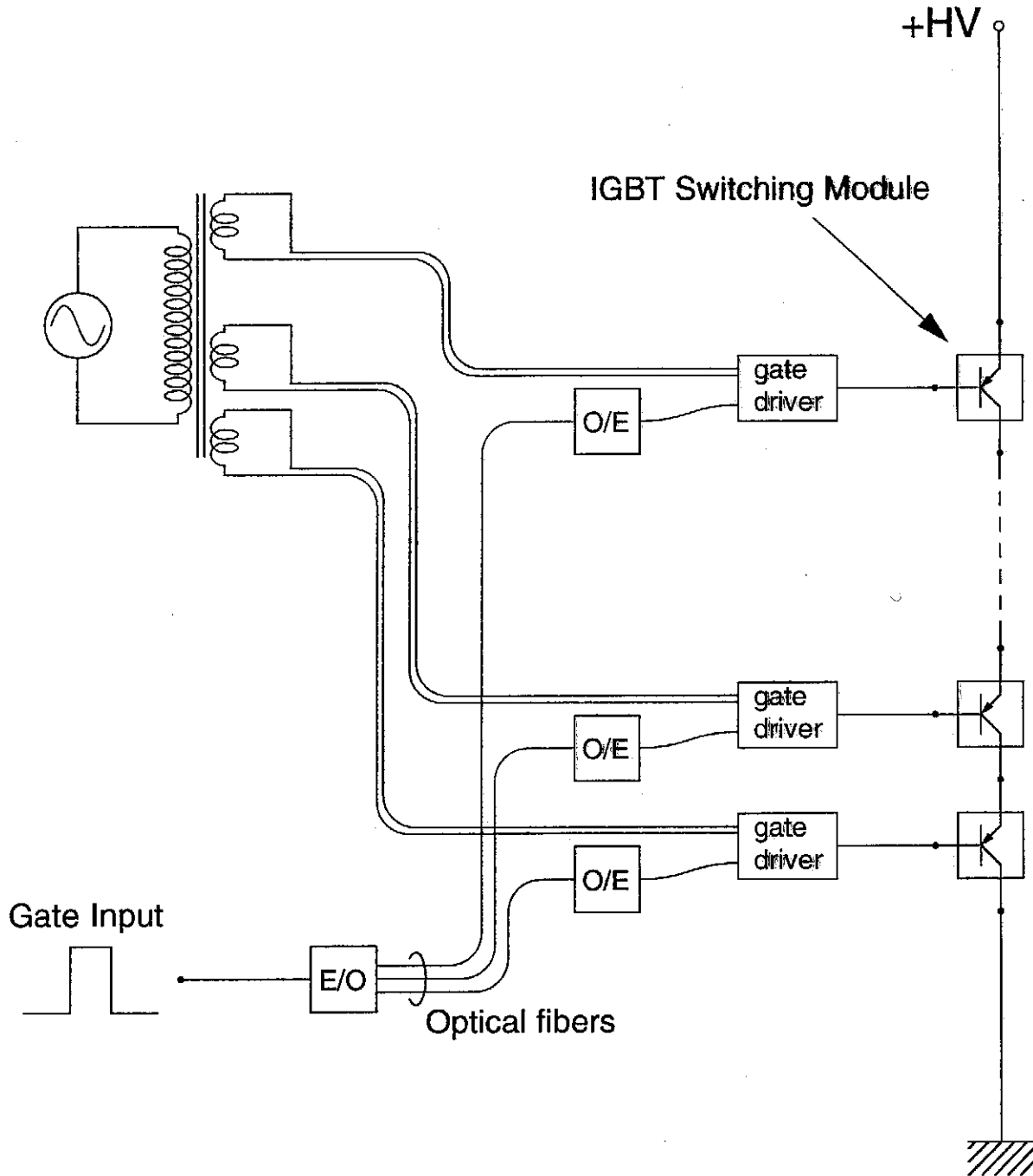


Subordinated Multi-stage Gating Circuit



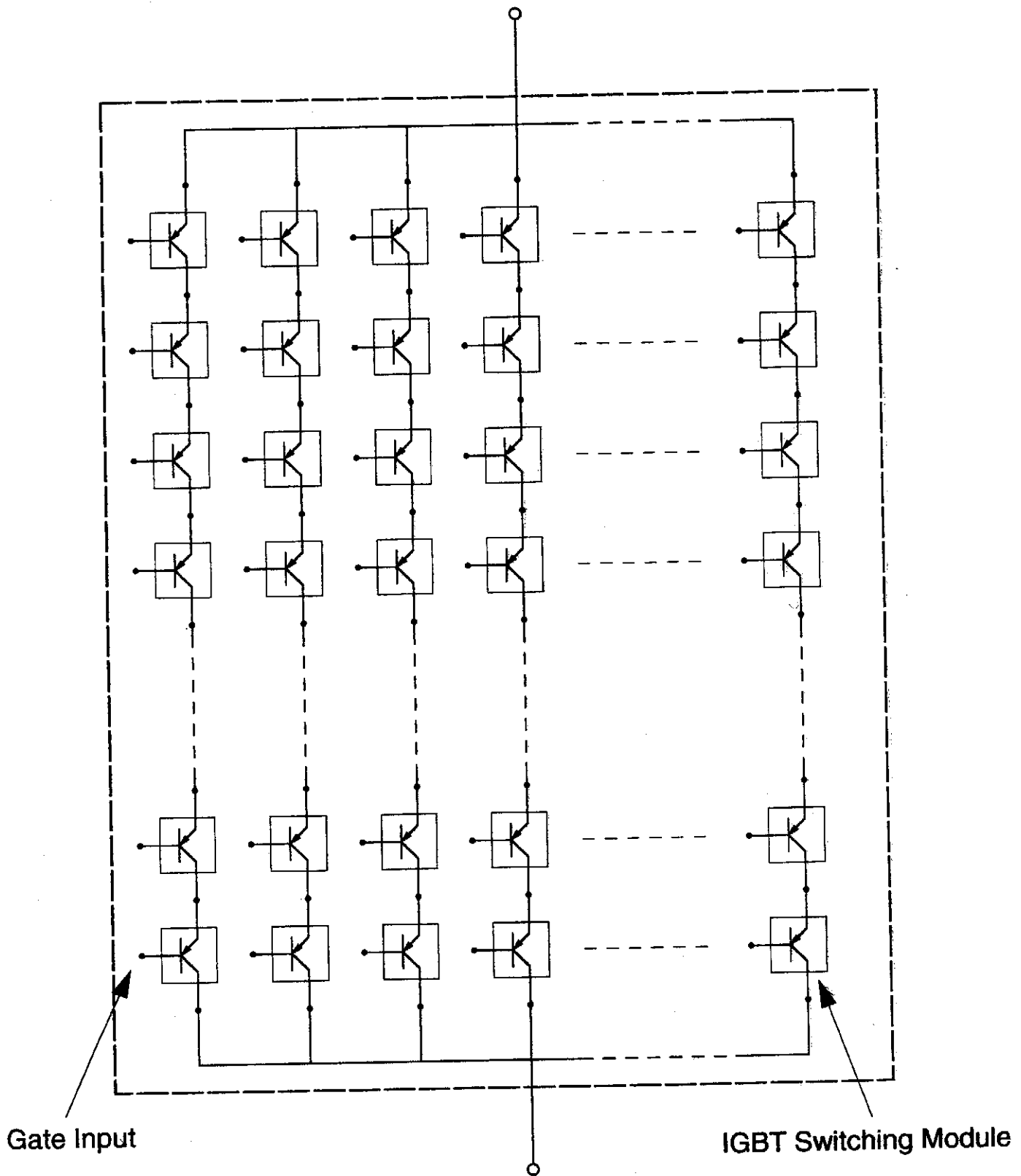
==> Simple and reliable

Conventional Multi-stage Gating Circuit



- ⇒ Complex gating circuit system
- ⇒ Insulation problems at the transformer

High Voltage Switch with Massive Parallel/Series Stages of IGBT Modules



R & D items :

In order to allow a higher voltage and higher current switching :

In order to allow a higher repetition rate switching :

---> Use of IGBT (Insulated Gate Bipolar Transistor) switching modules.

---> Use of a Subordinate-Driving switching system for a multi-stage turning-on.

In order to allow a stronger kicker field :

---> Use of Magnetic-Alloy as a return yoke.

Simple Evaluation of Basic Parameters

50GeV:

Gap Height : $h = 0.1 \text{ m}$

Field Strength : $B = 0.1 \text{ T}$

\implies Kicker Current : $I = B \cdot h / \mu_0 = \underline{8 \text{ kA}}$

PRISM/FFAG:

Gap Height : $h = 0.2 \text{ m}$

Field Strength : $B = 0.05 \text{ T}$

\implies Kicker Current : $I = B \cdot h / \mu_0 = \underline{8 \text{ kA}}$

PFN/Transmission-cable Impedance: $R_0 = 12.5 \Omega$

\implies PFN Charging Voltage:

$$\begin{aligned} E &= I \cdot R_0 \\ &= \underline{100 \text{ kV}} \end{aligned}$$

(Lumped type, with a full voltage-reflection at the terminal-end.)